



. 100102 11111 20101 1911 01181 1971 1971

Docket No.: 8733.428.00

TC 2800 MAIL ROOM

(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Yong-In Park, et al.

Application No.: 09/855,694

Filed: May 16, 2001

For: METHOD OF FABRICATING A THIN FILM TRANSISTOR AND MANUFACTURING

EQUIPMENT

5/Electron 5/31/02 Awell

Group Art Unit: 2823

Examiner: J. Maldonado

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents Washington, DC 20231

Dear Sir:

In response to the restriction requirement set forth in the Office Action mailed May 6, 2002, Applicants hereby provisionally elect claims 1-5 and 15-20 for continued examination.

The Examiner has required restriction between claims 1-5 and 15-20, drawn to a method of forming a semiconductor device, classified in class 438, subclass 149, and claims 6-14, drawn to an apparatus to fabricate a semiconductor device, classified in class 118, subclass 723.

Applicants believe the foregoing amendments place the application in condition for allowance and early, favorable action is respectfully solicited. Should the Examiner deem that a telephone conference would further the prosecution of this application, the Examiner is invited to call the undersigned attorney at (202) 624-1200.

If these papers are not considered timely filed by the Patent and Trademark Office, then a petition is hereby made under 37 C.F.R. § 1.136, and any additional fees required under 37 C.F.R. § 1.136 for any necessary extension of time, or any other fees required to complete the

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filing of this response, may be charged to Deposit Account No. 50-0911. Please credit any overpayment to Deposit Account No. 50-0911.

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Dated: May 28, 2002

Respectfully submitted,

Sorg K Lyng

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